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DRAM computation circuit and method

Abstract

A memory circuit includes a boundary layer, a first circuit positioned on a first side of the boundary layer and including a DRAM array including a plurality of DRAM cells, a second circuit positioned on a second side of the boundary layer opposite the first side and including a computation circuit, the computation circuit including a sense amplifier circuit, and a plurality of bit lines coupled to the plurality of DRAM cells and the sense amplifier circuit. Each bit line of the plurality of bit lines includes a via structure positioned in the boundary layer and the plurality of DRAM cells of the first circuit positioned on the first side of the boundary layer is an entirety of the DRAM cells of the memory circuit coupled to the sense amplifier circuit.

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Background/Summary

PRIORITY CLAIM (1) The present application is a continuation of U.S. application Ser. No. 17/589,729, filed Jan. 21, 2022, now U.S. Pat. No. 12,014,768. issued Jun. 18, 2024, which claims the priority of U.S. Provisional Application No. 63/226,902, filed Jul. 29, 2021, each of which is incorporated herein by reference in its entirety.

BACKGROUND

(1) Memory arrays are often used to store and access data used for various types of computations such as logic or mathematical operations. To perform these operations, data bits are moved between the memory arrays and circuits used to perform the computations. In some cases, computations include multiple layers of operations, and the results of a first operation are used as input data in a second operation.

Description

BRIEF DESCRIPTION OF THE DRAWINGS

- (1) Aspects of the present disclosure are best understood from the following detailed description when read with the accompanying figures. It is noted that, in accordance with the standard practice in the industry, various features are not drawn to scale. In fact, the dimensions of the various features may be arbitrarily increased or reduced for clarity of discussion.
- (2) FIGS. **1**A-**1**F are diagrams of memory circuits, in accordance with some embodiments.
- (3) FIG. **2** is a diagram of a computation circuit, in accordance with some embodiments.
- (4) FIG. **3** is a diagram of a computation circuit, in accordance with some embodiments.
- (5) FIG. **4** is a diagram of an adder tree circuit, in accordance with some embodiments.
- (6) FIG. **5** is a flowchart of a method of operating a memory circuit, in accordance with some embodiments.
- (7) FIG. **6** is a flowchart of a method of manufacturing a memory circuit, in accordance with some embodiments.

DETAILED DESCRIPTION

- (8) The following disclosure provides many different embodiments, or examples, for implementing different features of the provided subject matter. Specific examples of components, values, operations, materials, arrangements, or the like, are described below to simplify the present disclosure. These are, of course, merely examples and are not intended to be limiting. Other components, values, operations, materials, arrangements, or the like, are contemplated. For example, the formation of a first feature over or on a second feature in the description that follows may include embodiments in which the first and second features are formed in direct contact, and may also include embodiments in which additional features may be formed between the first and second features, such that the first and second features may not be in direct contact. In addition, the present disclosure may repeat reference numerals and/or letters in the various examples. This repetition is for the purpose of simplicity and clarity and does not in itself dictate a relationship between the various embodiments and/or configurations discussed.
- (9) Further, spatially relative terms, such as "beneath," "below," "lower," "above," "upper" and the like, may be used herein for ease of description to describe one element or feature's relationship to another element(s) or feature(s) as illustrated in the figures. The spatially relative terms are intended to encompass different orientations of the device in use or operation in addition to the

- orientation depicted in the figures. The apparatus may be otherwise oriented (rotated 90 degrees or at other orientations) and the spatially relative descriptors used herein may likewise be interpreted accordingly.
- (10) In various embodiments, a dynamic random-access memory (DRAM) array of a memory circuit is positioned in a first circuit, a computation circuit including a sense amplifier is positioned in a second circuit separated from the first circuit by a circuit boundary, and bit lines of the memory circuit include via structures positioned in the circuit boundary. The various embodiments are thereby configured to be capable of performing computation-in-memory (CIM) operations based on weight data elements stored in the DRAM array. Compared to other approaches, such memory circuits are capable of performing CIM operations based on high memory capacity using a smaller area and lower power level. In various applications, e.g., convolutional neural network (CNN) applications, the memory circuit embodiments enable the weight data elements to be efficiently applied to sets of input data elements in multiply-and-accumulate (MAC) and other operations. (11) FIGS. 1A and 1B are diagrams of a memory circuit 100, in accordance with some embodiments. FIG. 1A is a schematic representation of circuit 100 and FIG. 1B depicts a non-limiting example of a cross-sectional arrangement of memory circuit 100 including an X direction and a Z direction. FIGS. 1C-1F discussed below depict non-limiting examples of a portion of memory circuit 100 including the X direction and a Y direction.
- (12) Memory circuit **100** includes a DRAM array **100**A positioned in a circuit C**1** and a computation circuit **100**B including a sense amplifier circuit SA and positioned in a circuit C**2**. Circuit C**2** is separated from circuit C**1** by a boundary layer CB, also referred to as a circuit boundary CB in some embodiments. Each of circuits C**1** and C**2** and boundary layer CB has dimensions in two directions, e.g., the X and Y directions, substantially greater than a dimension in a third direction perpendicular to the first two directions, e.g., the Z direction, and boundary layer CB substantially overlaps each of circuits C**1** and C**2** along the third direction. In some embodiments, circuits C**1** and C**2** are referred to as integrated circuit (IC) device layers C**1** and C**2**, respectively.
- (13) Bit lines B11-B1M and B21-B2M are conductive paths that extend from DRAM array 100A to sense amplifier circuit SA of computation circuit 100B and include corresponding instances of via structures VS (a single instance labeled in FIG. 1A for clarity) positioned in one or more structural layers 100CB of boundary layer CB. In the embodiment depicted in FIG. 1B, DRAM array 100A includes a control circuit 110A, and memory circuit 100 includes control lines CL1 and CL2, conductive paths that extend from control circuit 110A to sense amplifier SA. Each of control lines CL1 and CL2 includes an instance of via structure VS positioned in one or more structural layers 100CB.
- (14) In the embodiment depicted in FIGS. **1**A and **1**B, circuit C**1** is positioned above circuit C**2** in the Z direction, and boundary layer CB is adjacent to each of circuits C**1** and C**2**. In some embodiments, circuit C**2** is positioned above circuit C**1** in the Z direction and/or boundary layer CB is adjacent to a single one or neither of circuits C**1** or C**2**, e.g., separated from one or both of circuits C**1** or C**2** by one or more additional layers (not shown).
- (15) In the embodiment depicted in FIG. **1**B, in addition to an instance of via structure VS, each of bit lines B**11**-B**1**M and B**21**-B**2**M and control lines CL**1** and CL**2** includes a conductive path LA in DRAM **100**A, a conductive path L**1** in boundary layer CB between conductive path LA and the instance of via structure VS, a conductive path LB in computation circuit **100**B, and a conductive path L**2** in boundary layer CB between conductive path LB and the instance of via structure VS. In some embodiments, one or more of bit lines B**11**-B**1**M or B**21**-B**2**M or control lines CL**1** or CL**2** does not include one or both of conductive paths L**1** or L**2**, e.g., by including an instance of via structure VS directly connected to one or both of conductive paths LA or LB.
- (16) Each of conductive paths LA and LB is a metal interconnect structure including one or more metal lines and/or via structures positioned within the corresponding circuit C1 or C2. Each

conductive path LA is configured to provide an electrical connection between one or more elements of DRAM **100**A and the corresponding conductive path L**1** or via structure VS, and each conductive path LB is configured to provide an electrical connection between one or more elements of computation circuit **100**B, e.g., sense amplifier SA, and the corresponding conductive path L**2** or via structure VS. In some embodiments, lowermost portions of conductive paths LA are positioned along a first X-Y plane at which DRAM **100**A is adjacent to boundary layer CB, and uppermost portions of conductive paths LB are positioned along a second X-Y plane, below the first X-Y plane, at which computation circuit **100**B is adjacent to boundary layer CB.

- (17) In the embodiment depicted in FIG. 1B, each of bit lines B11-B1M and B21-B2M and control lines CL1 and CL2 corresponds to a single instance of each of via structure VS and conductive paths LA, L1, L2, and LB. In some embodiments, a given one of bit lines B11-B1M or B21-B2M or control lines CL1 or CL2 corresponds to multiple instances of one or more of via structure VS or conductive paths LA, L1, L2, or LB. In some embodiments, a given one or more of via structure VS or conductive paths LA, L1, L2, or LB corresponds to multiple instances of bit lines B11-B1M or B21-B2M or control lines CL1 or CL2, e.g., embodiments in which multiple bit lines share an input to sense amplifier SA or embodiments in which a control line CL1 or CL2 includes multiple connections to sense amplifier SA.
- (18) In some embodiments, circuits C1 and C2 are IC device layers of an IC device package, e.g., a 3D IC package, and the one or more structural layers 100CB include elements configured to maintain a combination of a mechanical arrangement and electrical connections between IC devices of the IC device package. In some embodiments, each of circuits C1 and C2 includes some or all of a semiconductor wafer or die, e.g., in a wafer-on-wafer, die-on-wafer, or die-on-die arrangement. In some such embodiments, via structures VS include one or more chip bonding elements including one or more metal materials, e.g., solder balls or copper or other metal pillars or studs, and, if present, one or both of conductive paths L1 or L2 includes a pad or other similar structure positioned on or connected to the one or more semiconductor wafers or dies, via structure VS and conductive paths L1 and/or L2 thereby being suitable for providing electrical and/or mechanical connections between multiple semiconductor wafers and/or dies. In some embodiments, one or both of conductive paths L1 or L2 include one or more elements of one or more redistribution layers of an IC device package.
- (19) In some embodiments, the one or more structural layers **100**CB of boundary layer CB include one or more dielectric layers of an IC device package, the one or more dielectric layers including one or more electrically insulating materials, e.g., silicon dioxide (SiO.sub.2), an epoxy or encapsulation material, or the like. In some embodiments, the one or more structural layers **100**CB include one or more substrates, e.g., thin silicon layers, interposers, or the like, positioned between circuits C**1** and C**2**. In some embodiments, via structures VS include through-silicon via (TSV) structures positioned in the one or more structural layers **100**CB of an IC device package. (20) In some embodiments, via structures VS include TSV structures having widths ranging from less than 1 micron to 50 microns. In some embodiments, via structures VS include TSV structures having widths ranging from 1 micron to 10 microns. Other ranges and/or values are within the scope of the present disclosure. As widths of via structures VS increase, parasitic resistance, voltage drops, and power dissipation decrease.
- (21) In some embodiments, circuits C1 and C2 are positioned on a single substrate, e.g., a semiconductor wafer or die including silicon and/or other semiconductor material. In some such embodiments, the one or more structural layers 100CB of boundary layer CB include one or more dielectric and/or silicon layers within which via structures VS and, if present, conductive paths L1 and L2 are positioned. In some embodiments, each of conductive paths L1 and L2, if present, is a metal interconnect structure.
- (22) In some embodiments, via structures VS include one or more vias directly contacting one or both of conductive paths LA or LB of the corresponding circuit C1 or C2. In some embodiments,

- via structures VS include TSV structures positioned in the one or more structural layers **100**CB of a single substrate.
- (23) In some embodiments, via structures VS have widths ranging from 10 nanometers (nm) to 100 nm. In some embodiments, via structures VS have widths ranging from 25 nm to 75 nm. Other ranges and/or values are within the scope of the present disclosure. As widths of via structures VS decrease, area requirements decrease such that via structures VS are capable of connecting to DRAM array **100**A having a high density.
- (24) In the embodiment depicted in FIGS. **1**A and **1**B, instances of via structures VS are positioned in a single X-Z plane and are thereby configured to electrically connect DRAM array **100**A to computation circuit **100**B. In various embodiments, e.g., non-limiting examples discussed below with respect to FIGS. **1**C-**1**F, instances of via structures VS are otherwise positioned, e.g., in multiple X-Z planes, thereby being configured to electrically connect DRAM array **100**A to computation circuit **100**B.
- (25) In the embodiment depicted in FIGS. **1**A and **1**B, each via structure VS is included in one of bit lines B**11**-B**1**M and B**21**-B**2**M or control lines CL**1** and CL**2**. In some embodiments, memory circuit **100** includes one or more control lines (not shown) in addition to control lines CL**1** and CL**2**, and one or more instances of via structure VS are included in one or more of the additional control lines configured to carry one or more control signals and/or clock signals. The arrangement of bit lines B**11**-B**1**M and B**21**-B**2**M and control lines CL**1** and CL**2** depicted in FIG. **1**B is a non-limiting example provided for the purpose of illustration. Other arrangements, e.g., one or both of control lines CL**1** or CL**2** positioned between one or more pairs of bit lines B**11**-B**1**M or B**21**-B**2**M, are within the scope of the present disclosure.
- (26) DRAM array **100**A includes a plurality of DRAM cells MC (a single instance labeled in FIG. **1**A for clarity), also referred to as memory cells MC in some embodiments. In the embodiment depicted in FIG. **1**A, each DRAM cell MC includes a single NMOS transistor M**1** and a single capacitive device CD**1** coupled in series between a ground reference node (indicated by the analog ground symbol) and one of bit lines B**11**-B**1**M or B**21**-B**2**M corresponding to columns of DRAM cells MC. A gate of each transistor M**1** is coupled to one of signal lines CONV.sub.1-CONV.sub.N corresponding to rows of DRAM cells MC.
- (27) In the embodiment depicted in FIG. **1**A, DRAM array **100**A thereby includes DRAM cells MC configured to, responsive to signals (not labeled) received on signal lines CONV.sub.1-CONV.sub.N, receive and store data received on bit lines B11-B1M and B21-B2M, and output data to bit lines B11-B1M and B21-B2M, the data corresponding to bit line signals S11-S1M and S21-**S2**M. In some embodiments, DRAM array **100**A includes DRAM cells MC otherwise configured to store and output data based on bit line signals S11-S1M and S21-S2M responsive to signals received on signal lines CONV.sub.1-CONV.sub.N. In various embodiments, a DRAM cell MC includes a PMOS transistor M1, a reference node other than a ground reference node, e.g., a power supply voltage (VDD) node, one or more transistors in addition to transistor M1, and/or one or more capacitive devices in addition to capacitive device CD1. In various embodiments, DRAM array **100**A includes each DRAM cell MC coupled to multiple ones of bit lines B**11**-B**1**M and B**21**-B2M and/or bit lines B11-B1M and B21-B2M coupled to multiple DRAM cells MC in a same row. (28) In the embodiment depicted in FIGS. **1**A and **1**B, for the purpose of illustration, bit lines B**11**-B1M and B21-B2M and corresponding bit line signals S11-S1M and S21-S2M are arranged in two groups, each group including a number M of bit lines B11-B1M and B21-B2M and bit line signals S11-S1M and S21-S2M. In various embodiments, bit lines B11-B1M and B21-B2M and bit line signals S11-S1M and S21-S2M have arrangements other than that depicted in FIGS. 1A and 1B, e.g., including a single group or more than two groups, or including groups having varying numbers of bit lines and bit line signals.
- (29) DRAM array **100**A is capable of storing data having a volume and configuration based on values of a number of rows N corresponding to signal lines CONV.sub.1-CONV.sub.N, the number

- of groups of bit lines B11-B1M and B21-B2M, and the number M of each group of bit lines B11-B1M and B21-B2M. A number of columns of DRAM array 100A corresponds to the number of groups of bit lines B11-B1M and B21-B2M times the number M of each group. The total volume of data bits capable of being stored in DRAM array 100A thereby corresponds to the number of columns times the number of rows N.
- (30) In the embodiment depicted in FIGS. **1**A and **1**B, the number of columns of DRAM array **100**A is equal to the total number of bit lines B**11**-B**1**M and B**21**-B**2**M. In some embodiments, DRAM array **100**A is otherwise configured whereby the number of columns is greater than the total number of bit lines B**11**-B**1**M and B**21**-B**2**M, e.g., by including more than one column electrically connected to each one of bit lines B**11**-B**1**M and B**21**-B**2**M and/or including a selection circuit such as a multiplexer between two or more columns and each one of bit lines B**11**-B**1**M and B**21**-B**2**M.
- (31) As data storage capacity increases, the number and type of potential applications of DRAM array **100**A increase, and both array size and power consumption also increase. In some embodiments, DRAM array **100**A has a data storage capacity ranging from 1 kilobit (kb) to 128 gigabits (Gb). In some embodiments, DRAM array **100**A has a data storage capacity ranging from 1 megabit (Mb) to 16 Gb. In some embodiments, DRAM array **100**A has a data storage capacity ranging from 128 Mb to 1 Gb. Other ranges and/or values are within the scope of the present disclosure.
- (32) In some embodiments, the number M of each group of bit lines B11-B1M and B21-B2M is equal to eight, corresponding to a byte of eight data bits, and DRAM 100A is thereby configured to be compatible with conventional memory configurations. Other values are within the scope of the present disclosure. In some embodiments, DRAM array 100A has a data storage capacity ranging from 1 megabyte (MB) to 16 gigabytes (GB). In some embodiments, DRAM array 100A has a data storage capacity ranging from 128 MB to 1 GB. Other ranges and/or values are within the scope of the present disclosure.
- (33) In some embodiments, the number M of each group of bit lines B11-B1M and B21-B2M corresponds to a size of weight data elements stored in DRAM array 100A and used in one or more operations performed by computation circuit 100B, as discussed below. As the size of the weight data element increases, weight data precision increases along with complexity and execution time of the one or more operations performed by computation circuit 100B.
- (34) In some embodiments, weight data element size corresponds to the number M having a value ranging from 2 to 16. In some embodiments, weight data element size corresponds to the number M having a value ranging from 4 to 12. In some embodiments, weight data element size corresponds to the number M having a value equal to 8, the weight data elements thereby corresponding to data bytes. Other ranges and/or values are within the scope of the present disclosure.
- (35) As the number of groups of bit lines B11-B1M and B21-B2M increases, the number of rows N corresponding to a given data storage capacity of DRAM array 100A decreases, and a number of units of data, e.g., weight elements and/or bytes, capable of being stored per row thereby increases. In some embodiments, the number of groups of bit lines B11-B1M and B21-B2M has a value ranging from 512 to 1M. In some embodiments, the number of groups of bit lines B11-B1M and B21-B2M has a value ranging from 1 k to 128 k. In some embodiments, the number of groups of bit lines B11-B1M and B21-B2M has a value ranging from 4 k to 32 k. Other ranges and/or values are within the scope of the present disclosure.
- (36) As the number of rows N increases, the number of columns corresponding to a given data storage capacity of DRAM array **100**A decreases, thereby reducing the total number of bit lines B**11**-B**1**M and B**21**-B**2**M and a corresponding number of signals propagated to computation circuit **100**B in some embodiments. In some embodiments, the number of rows N has a value ranging from 8 to 128 k. In some embodiments, the number of rows N has a value ranging from 16 to 64 k.

- In some embodiments, the number of rows N has a value ranging from 128 to 32 k. Other ranges and/or values are within the scope of the present disclosure.
- (37) Computation circuit **100**B is an IC configured to detect bit line signals S**11**-S**1**M and S**21**-S**2**M on bit lines B**11**-B**1**M and B**21**-B**2**M, receive an input signal IN on an input port INP, and generate an output signal OUT on an output port OUTP by performing one or more operations based on signals S**11**-S**1**M and S**21**-S**2**M and input signal IN.
- (38) Bit line signals S11-S1M and S21-S2M are electronic signals having voltage and/or current levels indicative of logical states of DRAM cells MC in a read operation of memory circuit 100. In some embodiments, a bit line signal S11-S1M or S21-S2M has a voltage level above a reference voltage level responsive to a charged state of capacitive device CD1 of a corresponding DRAM cell MC in a read operation, and a voltage level below the reference voltage level responsive to a discharged state of capacitive device CD1 of the corresponding DRAM cell MC in the read operation. In some embodiments, a reference voltage level is a midpoint between a ground reference voltage level and a power supply voltage level.
- (39) Control circuit **110**A is an electronic circuit configured to generate and/or propagate one or more control and/or clock signals configured to control operation of DRAM **100**A during read, write, and other operations. Memory circuit **100** is configured to propagate a first subset or all of the control and/or clock signals within DRAM **100**A and propagate a second subset or all of the control and/or clock signals (represented in FIG. **1B** as signals CS**1** and CS**2**) to computation circuit **100**B through control lines, e.g., control lines CL**1** and CL**2**, positioned in boundary layer CB.
- (40) In the embodiment depicted in FIG. 1B, an entirety of control circuit 110A is positioned within circuit C1 such that signals CS1 and CS2 are propagated from circuit C1 to circuit C2 through boundary layer CB. In some embodiments, an entirety of control circuit 110A is positioned within circuit C2 such that signals CS1 and CS2 are propagated from circuit C2 to circuit C1 through boundary layer CB. In some embodiments, control circuit 110A is distributed among circuits C1 and C2 such that a first portion of signals CS1 and CS2 are propagated from circuit C1 to circuit C2 through boundary layer CB and a second portion of signals CS1 and CS2 are propagated from circuit C2 to circuit C1 through boundary layer CB.
- (41) In some embodiments, memory circuit **100** is configured to generate and propagate signals CS**1** and CS**2** configured to synchronize one or more timings of DRAM **100**A and computation circuit **100**B during various operations as discussed below.
- (42) Memory circuit **100** is configured to propagate bit line signals S**11**-S**1**M and S**21**-S**2**M on bit lines B**11**-B**1**M and B**21**-B**2**M and signals CS**1** and CS**2** on control lines CL**1** and CL**1** though via structures VS having various arrangements as illustrated by the non-limiting examples depicted in FIGS. **1C-1**F. Each of FIGS. **1C-1**F includes the X and Y directions and a portion of boundary layer CB including multiple instances of via structure VS positioned in the one or more structural layers **100**CB.
- (43) Each of the embodiments depicted in FIGS. **1**C-**1**F is simplified for the purpose of illustration. In various embodiments, boundary layer CB includes one or more elements in addition to those depicted in FIGS. **1**C-**1**F, e.g., one or more instances of conductive path L**1** and/or L**2** electrically connected to one or more instances of via structure VS.
- (44) In the embodiment depicted in FIG. **1**C, a single row of via structures VS extends in the X direction in accordance with the embodiment depicted in FIGS. **1**A and **1**B. In some embodiments, a single row of via structures VS extends in the Y direction.
- (45) The embodiment depicted in FIG. **1**D includes first and second rows of via structures VS extending the X direction. The via structures VS in a given row are aligned in the Y direction with spaces between the via structures VS of the adjacent row. In some embodiments, the arrangement depicted in FIG. **1**D corresponds to bit lines, e.g., bit lines B**11**-B**1**M and B**21**-B**2**M, and/or control lines, e.g., control lines CL**1** and CL**2**, extending in the Y direction, the via structures VS of the

- first row being electrically connected to a first subset of the bit and/or control lines and the via structures VS of the second row being electrically connected to a second subset of the bit and/or control lines alternating with the first subset.
- (46) In the embodiment depicted in FIG. **1**E, an array includes rows of via structures VS extending in the X direction, the instances of via structures VS being aligned in columns extending in the Y direction.
- (47) In the embodiment depicted in FIG. **1F**, instances of via structures VS are electrically connected to instances of conductive path L**1** extending in the Y direction. The instances of conductive path L**1** correspond to an embodiment of DRAM **100**A in which a first sub-array includes bit lines B**11**A, B**12**A, B**1**MA and a second sub-array includes bit lines B**11**B, B**12**B, B**1**MB, each electrically connected to the corresponding instances of conductive path L**1**. The sub-arrays are thereby configured to share electrical connections to sense amplifier SA through the corresponding instances of via structure VS. In some embodiments, the sub-arrays are otherwise configured to share electrical connections to sense amplifier SA through corresponding instances of via structure VS, e.g., by including multiple electrical connections in conductive path LA instead of conductive path L**1**.
- (48) The embodiments depicted in FIGS. 1C-1F are non-limiting examples presented for the purpose of illustration. Other arrangements of instances of via structures VS are within the scope of the present disclosure. In some embodiments, the arrangement of via structures VS in boundary layer CB includes one or more combinations of the embodiments depicted in FIGS. 1C-1F. (49) Computation circuit 100B includes sense amplifier circuit SA configured to generate sense amplifier signals based on bit line signals S11-S1M and S21-S2M received on bit lines B11-B1M and B21-B2M though via structures VS, the sense amplifier signals thereby being indicative of the logical states of corresponding DRAM cells MC in the read operation of memory circuit 100. In various embodiments, sense amplifier SA is configured to generate sense amplifier signals as digital signals, e.g., sense amplifier signals DS11-DS1M and DS21-DS2M discussed below with respect to FIG. 2, or to generate sense amplifier signals as analog signals, e.g., sense amplifier signals AS11-AS1M and AS21-AS2M discussed below with respect to FIG. 3.
- (50) Input signal IN, also referred to as an input vector IN in some embodiments, is one or more electronic signals including signal levels corresponding to a plurality of input data elements. In some embodiments, each data element of the plurality of data elements includes a plurality of data bits, e.g., eight data bits corresponding to a data byte. In some embodiments, computation circuit **100**B includes a selection circuit (not shown) configured to, in operation, select individual bits of each data element of the plurality of data elements, e.g., sequentially. In various embodiments, input port INP includes a parallel or serial port configured to receive input signal IN.
- (51) As a number and size of data elements of input signal IN increases, the number and types of potential applications of computation circuit **100**B increase, and circuit complexity also increases. In some embodiments, computation circuit **100**B is configured to receive input signal IN including the number of data elements ranging from 8 to 1M. In some embodiments, computation circuit **100**B is configured to receive input signal IN including the number of data elements ranging from 1 k to 500 k. In some embodiments, computation circuit **100**B is configured to receive input signal IN including the number of data elements ranging from 50 k to 200 k. Other ranges and/or values are within the scope of the present disclosure.
- (52) In some embodiments, computation circuit **100**B is configured to receive input signal IN including data elements having a number of bits ranging from 2 to 16. In some embodiments, computation circuit **100**B is configured to receive input signal IN including data elements having the number of bits ranging from 4 to 12. In some embodiments, computation circuit **100**B is configured to receive input signal IN including data elements having 8 bits. Other ranges and/or values are within the scope of the present disclosure.
- (53) Computation circuit 100B is configured to generate output signal OUT, also referred to as an

- output vector OUT, as a data signal including multiple data elements, each data element including a plurality of data bits. Increasing number and size of the data elements of output signal OUT correspond to increasing numbers and types of potential applications of computation circuit **100**B, and to increasing circuit complexity. In various embodiments, output port OUTP includes a parallel or serial port configured to propagate output signal OUT.
- (54) In some embodiments, computation circuit **100**B is configured to generate output signal OUT including the number of data elements ranging from 8 to 100 k. In some embodiments, computation circuit **100**B is configured to generate output signal OUT including the number of data elements ranging from 100 to 50 k. In some embodiments, computation circuit **100**B is configured to generate output signal OUT including the number of data elements ranging from 500 to 5 k. Other ranges and/or values are within the scope of the present disclosure.
- (55) In some embodiments, computation circuit **100**B is configured to generate output signal OUT including data elements having a number of bits ranging from 2 to 16. In some embodiments, computation circuit **100**B is configured to generate output signal OUT including data elements having the number of bits ranging from 4 to 12. In some embodiments, computation circuit **100**B is configured to generate output signal OUT including data elements having 8 bits. Other ranges and/or values are within the scope of the present disclosure.
- (56) Computation circuit **100**B is configured to perform the one or more operations by logically combining the sense amplifier output signals with input signal IN. In some embodiments in which DRAM array **100**A is configured to store weight data elements, input signal IN corresponds to input elements of a neural network, e.g., a CNN, and/or input elements of a neural network layer, e.g., a hidden layer.
- (57) In some embodiments, computation circuit **100**B is configured to combine the sense amplifier output signals with data elements of input signal IN by performing one or more matrix operations, e.g., a MAC operation. In some embodiments, computation circuit **100**B is configured to combine the sense amplifier output signals with data elements of input signal IN by performing one or more of a summation function, a scaling function, or a rectified linear unit (ReLU) function.
- (58) In some embodiments, computation circuit **100**B is configured to combine the sense amplifier output signals with data elements of input signal IN by sequentially selecting data bits of each data element of input signal IN. In some embodiments, computation circuit **100**B is configured to combine the sense amplifier output signals with data elements of input signal IN by sequentially selecting some or all of rows CONV.sub.1-CONV.sub.N in a series of read operations.

 (59) In some embodiments, memory circuit **100** is configured as a neural network in which
- computation circuit **100**B is configured to perform a sequence of operations corresponding to layers of the neural network based on weight data elements stored in DRAM array **100**A. In such embodiments, input signal IN is the input to a first layer of the neural network, and output data of the first and successive layers are input data to corresponding subsequent layers of the neural network, with the output data of the final layer corresponding to output signal OUT. At each layer of the neural network, computation circuit **100**B is configured to perform at least one of the one or more operations based on a subset of the weight data elements accessed by sequential read operations on DRAM array **100**A. In some embodiments, memory circuit **100** is configured as a sixteen layer visual geometry group (VGG-16) CNN configured to receive input signal IN including data elements corresponding to a visual image. Other numbers of layers and/or types of neural networks are within the scope of the present disclosure.
- (60) In some embodiments, each row of rows CONV.sub.1-CONV.sub.N is configured to store the weight data elements corresponding to a single layer of a neural network. In various embodiments, one or more individual rows of rows CONV.sub.1-CONV.sub.N are configured to store the weight data elements corresponding to multiple layers of a neural network, and/or multiple rows of rows CONV.sub.1-CONV.sub.N are configured to store the weight data elements corresponding to a single layer of a neural network.

- (61) By the configuration discussed above, memory circuit **100** is capable of performing CIM operations using computation circuit **100**B based on weight data elements stored in DRAM array **100**A. Compared to other approaches, memory circuit **100** is capable of performing CIM operations based on high memory capacity using a smaller area and lower power level. In various applications, e.g., CNN applications, memory circuit **100** enables the weight data elements to be efficiently applied to input signal IN as part of MAC and other matrix operations.
- (62) FIG. **2** is a diagram of a computation circuit **200**, in accordance with some embodiments. Computation circuit **200** is usable as some or all of computation circuit **100**B discussed above with respect to FIGS. **1**A-**1**F.
- (63) Computation circuit **200** is an IC including a sense amplifier circuit DSA, NOR gates NG (a single instance labeled for clarity), and an adder tree circuit **200**T. Sense amplifier circuit DSA is usable as sense amplifier SA, discussed above with respect to FIGS. **1**A-**1**F, and includes input terminals coupled to bit lines B**11**-B**1**M and B**21**-B**2**M, and output terminals coupled to first input terminals of NOR gates NG. NOR gates NG include second input terminals coupled to input port INP and configured to receive portions of input signal IN as discussed below, and output terminals coupled to input terminals of adder tree circuit **200**T. Adder tree circuit **200**T is coupled to output port OUTP.
- (64) Sense amplifier circuit DSA is an IC including sense amplifiers DA (a single instance labeled for clarity) configured to receive bit line signals S11-S1M and S21-S2M on bit lines B11-B1M and B21-B2M, and generate sense amplifier signals DS11-DS1M and DS21-DS2M as digital signals indicative of voltage and/or current levels of bit line signals S11-S1M and S21-S2M. In some embodiments, sense amplifiers DA include cross-coupled transistors configured to generate sense amplifier signals DS11-DS1M and DS21-DS2M having logical states based on voltage levels of bit line signals S11-S1M and S21-S2M relative to a reference voltage level, as discussed above with respect to FIGS. 1A and 1B.
- (65) In the embodiment depicted in FIG. **2**, each instance of sense amplifier DA is coupled to a single one of bit lines B**11**-B**1**M or B**21**-B**2**M. In some embodiments, each of one or more instances of sense amplifier DA is coupled to two or more of bit lines B**11**-B**1**M or B**21**-B**2**M. (66) In the embodiment depicted in FIG. **2**, sense amplifier circuit DSA includes sense amplifiers DA configured to receive bit line signals S**11**-S**1**M and S**21**-S**2**M and generate sense amplifier signals DS**11**-DS**1**M and DS**21**-DS**2**M having the number M equal to 8, thereby corresponding to byte-size weight data elements W.sub.111-W.sub.118 and W.sub.121-W.sub.128. In the non-limiting example depicted in FIG. **2**, weight data elements W.sub.111-W.sub.118 and W.sub.121-W.sub.128 correspond to data stored in row CONV.sub.1, weight data elements W.sub.111-W.sub.118 correspond to the eight bits of a first weight data element, and weight data elements W.sub.121-W.sub.128 correspond to the eight bits of a second weight data element.
- (67) In some embodiments, sense amplifier circuit DSA includes sense amplifiers DA configured to receive bit line signals S11-S1M and S21-S2M and generate sense amplifier signals DS11-DS1M and DS21-DS2M having the number M equal to a value other than 8, as discussed above with respect to FIGS. 1A and 1B.
- (68) In the embodiment depicted in FIG. **2**, NOR gates NG are arranged in groups corresponding to the groups of bit lines B**11**-B**1**M and B**21**-B**2**M, each group including the number M of NOR gates NG. The second input terminal of each NOR gate NG within a given group is configured to receive a same portion of input signal IN, e.g., a same bit of a same data element corresponding to a particular sequence step.
- (69) In the embodiment depicted in FIG. **2**, a first group of NOR gates NG is configured to receive portion IN_B.sub.0 of input signal IN, and a second group of NOR gates NG is configured to receive portion IN_B.sub.1 of input signal IN. In some embodiments, NOR gates NG include groups configured to receive a number of portions of input signal IN greater than two. (70) NOR gates NG are thereby configured to generate NOR signals N**11**-N**1**M and N**21**-N**2**M

based on the logical states of sense amplifier signals DS11-DS1M and DS21-DS2M and the portions of input signal IN corresponding to the NOR gate NG groups.

- (71) Adder tree circuit **200**T is an IC including adders (not shown in FIG. **2**) configured to generate a summation data element based on NOR signals N11-N1M and N21-N2M received from NOR gates NG. In some embodiments, the summation data element is some or all of output signal OUT. In some embodiments, adder tree circuit **200**T includes one more circuit elements (not shown), e.g., an accumulator circuit, configured to generate some or all of output signal OUT based on the summation data element. In some embodiments, the one or more circuit elements are configured to generate some or all of output signal OUT based on multiple instances of summation data elements, e.g., generated sequentially in operation. In some embodiments, adder tree circuit 200T includes one or more instances of an adder tree circuit **400** discussed below with respect to FIG. **4**. (72) An adder is an electronic circuit including one or more logic gates configured to perform a mathematical operation, e.g., addition, based on received first and second data elements, e.g., first and second ones of NOR signals N11-N1M and N21-N2M, thereby generating a sum data element equal to the sum of the received first and second data elements. In some embodiments, the adder is configured to generate the sum data element including a number of bits one greater than the number of bits of each of the received first and second data elements. In various embodiments, the adder includes one or more full adder gates, half adder gates, ripple-carry adder circuits, carry-save adder circuits, carry-select adder circuits, carry-look-ahead adder circuits, or other circuits suitable for performing some or all of an addition operation.
- (73) By the configuration discussed above, computation circuit **200** is capable of performing some or all of the operations, e.g., matrix operations, whereby output signal OUT is generated on output port OUTP, the one or more operations being based on bit line signals S**11**-S**1**M and S**21**-S**2**M and input signal IN. A memory circuit including computation circuit **200** is thereby capable of realizing the benefits discussed above with respect to memory circuit **100**.
- (74) FIG. **3** is a diagram of a computation circuit **300**, in accordance with some embodiments. Computation circuit **300** is usable as some or all of computation circuit **100**B discussed above with respect to FIGS. **1**A-**1**F.
- (75) Computation circuit **300** is an IC including a sense amplifier circuit ASA and an analog-to-digital-converter (ADC) circuit **300**ADC including, in some embodiments, adder tree circuit **200**T discussed above with respect to FIG. **2**. Sense amplifier circuit ASA is usable as sense amplifier SA, discussed above with respect to FIGS. **1**A-**1**F, and includes input terminals coupled to bit lines B**11**-B**1**M and B**21**-B**2**M, and output terminals coupled to input terminals of ADC circuit **300**ADC. ADC circuit **300**ADC is coupled to each of input port INP and output port OUTP.
- (76) Sense amplifier circuit ASA is an IC including sense amplifiers AA (a single instance labeled for clarity) configured to receive bit line signals S11-S1M and S21-S2M on bit lines B11-B1M and B21-B2M, and generate sense amplifier signals AS11-AS1M and AS21-AS2M as analog signals indicative of voltage and/or current levels of bit line signals S11-S1M and S21-S2M. In some embodiments, sense amplifiers SA include buffers or the like configured to generate sense amplifier signals AS11-AS1M and AS21-AS2M having voltage magnitudes based on voltage and/or current levels of bit line signals S11-S1M and S21-S2M.
- (77) ADC circuit **300**ADC is an IC configured to generate output signal OUT on output port OUTP by performing one or more operations based on sense amplifier signals AS**11**-AS**1**M and AS**21**-AS**2**M received from sense amplifier circuit ASA, and input signal IN received on input port INP. In some embodiments, ADC circuit **300**ADC is configured to generate output signal OUT by performing one or more of a matrix computation, a summation function, a scaling function, or a ReLU function. In some embodiments, ADC circuit **300**ADC includes adder tree circuit **200**T configured to perform the summation function. In some embodiments, ADC circuit **300**ADC includes one more circuit elements (not shown), e.g., an accumulator circuit, configured to perform one or more operations as part of generating some or all of output signal OUT.

- (78) By the configuration discussed above, computation circuit **300** is capable of performing some or all of the operations, e.g., matrix operations, whereby output signal OUT is generated on output port OUTP, the one or more operations being based on bit line signals S11-S1M and S21-S2M and input signal IN. A memory circuit including computation circuit **300** is thereby capable of realizing the benefits discussed above with respect to memory circuit **100**.
- (79) FIG. **4** is a diagram of adder tree circuit **400**, in accordance with some embodiments. Adder tree circuit **400** is usable as some or all of adder tree circuit **200**T discussed above with respect to FIGS. **2** and **3**. Adder tree circuit **400** includes a number u of layers of adders ADD**1**-ADDu. (80) A first layer of adders includes adders ADD**1** configured to receive a number U (=2u) of data elements SUM**11**-SUM**1**U, the first layer thereby including a number U/2 of adders ADD**1**. In some embodiments, data elements SUM**11**-SUM**1**U correspond to some or all of NOR signals N**11**-N**1**M and N**21**-N**2**M discussed above with respect to FIG. **2**. In some embodiments, data elements SUM**11**-SUM**1**U correspond to internal signals of ADC circuit **300**ADC discussed above with respect to FIG. **3**.
- (81) Each adder ADD1 is configured to perform an addition operation on a corresponding received pair of data elements, e.g., SUM11 and SUM12, of data elements SUM11-SUM1U, and output the sum as a corresponding one of data elements SUM21-SUM2 (U/2). Adders ADD1 are configured to receive data elements SUM11-SUM1U including a first number of bits, and output data elements SUM21-SUM2 (U/2) including a second number of bits one greater than the first number of bits. (82) A second layer of adders includes a number U/4 of adders ADD2. Each adder ADD2 is configured to perform an addition operation on a corresponding received pair of data elements, e.g., SUM21 and SUM22, of data elements SUM21-SUM2 (U/2), and output the sum as a corresponding one of data elements SUM31-SUM3 (U/4). Adders ADD2 are configured to receive data elements SUM21-SUM2 (U/2) including the second number of bits and output data elements SUM**31**-SUM**3** (U/4) including a third number of bits one greater than the second number of bits. (83) A last layer of adders includes the single adder ADDu configured to perform an addition operation on a pair of data elements SUMu1 and SUMu2 received from a preceding layer of adders, and output the sum as a summation data element SDm. Adder ADDu is configured to receive data elements SUMu1 and SUMu2 including a fourth number of bits and output summation data element SDm including a fifth number of bits one greater than the fourth number of bits and equal to the first number of bits plus the number u. In some embodiments, e.g., those in which adder tree circuit **400** is used as some or all of adder tree circuit **200**T, summation data element SDm corresponds to some or all of output signal OUT discussed above with respect to FIGS. 1A-3. (84) In various embodiments, adder tree circuit **400** includes one or more additional layers of adders between the second and last layers depicted in FIG. 4, each additional layer being configured consistently with the configurations of the first, second, and last layers discussed above such that, in operation, summation data element SDm is generated based on received data elements SUM11-SUM1U. In some embodiments, adder tree circuit 400 does not include the second layer of adders ADD2, and thereby includes a total of u=2 layers such that, in operation, summation data element SDm is generated based on a total of U=4 data elements SUM11-SUM1U. (85) As the total number of layers increases, the number of potential applications of adder tree circuit **400** increases along with circuit size and complexity. In some embodiments, adder tree circuit **400** includes the total number of layers ranging from 2 to 9. In some embodiments, adder
- (86) Adder tree circuit **400** is thereby configured to be capable of performing the operations discussed above with respect to adder tree circuit **200**T and FIGS. **2** and **3**. By including adder tree circuit **400** as some or all of adder tree circuit **200**T in one of computation circuits **200** or **300**, a memory circuit is capable of realizing the benefits discussed above with respect to memory circuit **100**.

tree circuit **400** includes the total number of layers ranging from 4 to 7.

(87) FIG. 5 is a flowchart of a method 500 of operating a memory circuit, in accordance with some

- embodiments. Method **500** is usable with a memory circuit, e.g., memory circuit **100** discussed above with respect to FIGS. **1**A-**4**.
- (88) The sequence in which the operations of method **500** are depicted in FIG. **5** is for illustration only; the operations of method **500** are capable of being executed simultaneously or in sequences that differ from that depicted in FIG. **5**. In some embodiments, operations in addition to those depicted in FIG. **5** are performed before, between, during, and/or after the operations depicted in FIG. **5**. In some embodiments, the operations of method **500** are a subset of a method of operating a neural network.
- (89) At operation **510**, in some embodiments, weight data elements are stored in a DRAM array positioned in a first circuit. In some embodiments, storing the weight data elements includes storing weight data corresponding to one or more layers of a neural network. In some embodiments, storing the weight data elements in the DRAM array includes storing weight data in rows corresponding to layers of the neural network. In some embodiments, storing the weight data elements includes storing weight data corresponding to a VGG-16 CNN.
- (90) In some embodiments, storing the weight data elements in the DRAM array positioned in the first circuit includes the first circuit being some or all of a first semiconductor wafer or die of an IC package. In some embodiments, storing the weight data elements in the DRAM array positioned in the first circuit includes the first circuit being some or all of a first layer within a semiconductor wafer or die. In some embodiments, storing the weight data elements in the DRAM array positioned in the first circuit includes storing weight data in DRAM array **100**A positioned in circuit C1 of memory circuit **100**, discussed above with respect to FIGS. **1**A-**1**F.
- (91) At operation **520**, based on the weight data elements, bit line signals are generated on bit lines positioned in the first circuit. Generating the bit line signals on the bit lines includes selecting a subset of the weight data elements stored in a row of memory cells of the DRAM array as part of performing a read operation on the DRAM array. In some embodiments, selecting the subset of the weight data elements includes selecting a row CONV.sub.1-CONV.sub.N of memory cells MC as part of a read operation on DRAM array **100**A, discussed above with respect to FIGS. **1A-1**F. (92) At operation **530**, the bit line signals are propagated along via structures positioned between the first circuit and a second circuit underlying the first circuit. In some embodiments, propagating the bit line signals includes using via structures positioned between semiconductor wafers and/or
- dies of an IC package. In some embodiments, propagating the bit line signals includes using via structures positioned between layers of a semiconductor wafer or die. In some embodiments, propagating the bit line signals includes propagating bit line signals S11-S1M and S21-S2M using via structures VS discussed above with respect to FIGS. 1A-1F.
- (93) In some embodiments, propagating the bit line signals includes propagating one or more of control and/or clock signals CS1 and CS2, discussed above with respect to FIGS. 1A-1F, along via structures positioned between the first and second circuits.
- (94) At operation **540**, the bit line signals are received at a sense amplifier circuit of a computation circuit positioned in the second circuit. Receiving the bit line signals at the sense amplifier circuit of the computation circuit positioned in the second circuit includes receiving the bit line signals at the computation circuit positioned in the second circuit located above or below the first circuit. (95) In some embodiments, receiving the bit line signals at the computation circuit positioned in the second circuit includes receiving the bit line signals in a second semiconductor wafer and/or die of an IC package. In some embodiments, receiving the bit line signals at the computation circuit positioned in the second circuit includes receiving the bit line signals in a second layer of a
- circuit positioned in the second circuit includes receiving bit line signals S11-S1M and S21-S2M at computation circuit 100B positioned in circuit C2 of memory circuit 100, discussed above with respect to FIGS. 1A-1F.

semiconductor wafer or die. In some embodiments, receiving the bit line signals at the computation

(96) In some embodiments, receiving the bit line signals at the sense amplifier circuit of the

- computation circuit includes receiving bit line signals S11-S1M and S21-S2M at sense amplifier circuit DSA of computation circuit 200 discussed above with respect to FIG. 2. In some embodiments, receiving the bit line signals at the sense amplifier circuit of the computation circuit includes receiving bit line signals S11-S1M and S21-S2M at sense amplifier circuit ASA of computation circuit 300 discussed above with respect to FIG. 3.
- (97) At operation **550**, the computation circuit is used to generate an output signal by performing one or more operations based on an input signal and sense amplifier signals generated by the sense amplifier circuit. Performing the one or more operations includes performing one or more matrix operations, e.g., a MAC computation, a summation function, a scaling function, or a ReLU function.
- (98) In some embodiments, using the computation circuit includes using computation circuit **100**B discussed above with respect to FIGS. **1**A-**1**F. In some embodiments, using the computation circuit includes using computation circuit **200** discussed above with respect to FIG. **2**. In some embodiments, using the computation circuit includes using computation circuit **300** discussed above with respect to FIG. **3**.
- (99) In some embodiments, generating the output signal by performing the one or more operations based on the input signal includes generating output signal OUT by performing the one or more operations based on input signal IN as discussed above with respect to FIGS. **1**A-**4**.
- (100) In some embodiments, performing the one or more operations based on the sense amplifier signals generated by the sense amplifier circuit includes using the sense amplifier circuit to generate the sense amplifier signals as digital or analog signals based on the bit line signals received at the sense amplifier circuit.
- (101) In some embodiments, performing the one or more operations based on the sense amplifier signals generated by the sense amplifier circuit includes performing the one or more operations based on sense amplifier signals DS11-DS1M and DS21-DS2M generated by sense amplifier circuit DSA as discussed above with respect to FIG. 2. In some embodiments, performing the one or more operations based on the sense amplifier signals generated by the sense amplifier circuit includes performing the one or more operations based on sense amplifier signals AS11-AS1M and AS21-AS2M generated by sense amplifier circuit ASA as discussed above with respect to FIG. 3. (102) In some embodiments, performing the one or more operations includes using and adder tree circuit to perform the summation operation includes using adder tree circuit 200T as discussed above with respect to FIGS. 2 and 3. In some embodiments, using the adder tree circuit to perform the summation operation includes using adder tree circuit 400 as discussed above with respect to FIG.
- (103) In some embodiments, performing the one or more operations includes synchronizing the one or more operations with one or more operations of the DRAM array, e.g, by using control and/or clock signals CS1 and CS2 discussed above with respect to FIGS. 1A-1F.
- (104) At operation **560**, in some embodiments, some or all of operations **510-560** are repeated. In some embodiments, repeating some or all of operations **510-550** includes synchronizing execution of some or all of operations **510-550**, e.g., by using control and/or clock signals CS**1** and CS**2** discussed above with respect to FIGS. **1**A-**1**F.
- (105) In some embodiments, repeating some or all of operations **510-550** includes each instance of some or all of operations **510-550** corresponding to performing some or all of the matrix operations a step of a multi-step operation of a layer of a neural network. In some embodiments, repeating some or all of operations **510-550** includes each instance of some or all of operations **510-550** corresponding to performing some or all of operations **510-550** includes each instance of some or all of operations **510-550** corresponding to performing some or all of the operations of a layer of a VGG-16 CNN.

- (106) By executing some or all of the operations of method **500**, weight data elements stored in a DRAM array positioned in a first circuit are used in one or more operations of a neural network performed by a computation circuit positioned in a second circuit, thereby realizing the benefits discussed above with respect to memory circuit **100**.
- (107) FIG. **6** is a flowchart of a method **600** of manufacturing an IC device, in accordance with some embodiments. Method **600** is operable to form a memory circuit **100** discussed above with respect to FIGS. **1**A-**4**. In some embodiments, operations of method **600** are a subset of operations of a method of forming an IC package, e.g., a 2.5D IC package, a 3D IC package, or an InFO package. In some embodiments, operations of method **600** are a subset of operations of a method of forming a semiconductor wafer or die.
- (108) In some embodiments, the operations of method **600** are performed in the order depicted in FIG. **6**. In some embodiments, the operations of method **600** are performed in an order other than the order depicted in FIG. **6**. In some embodiments, one or more additional operations are performed before, during, between, and/or after the operations of method **600**.
- (109) At operation **610**, in some embodiments, a partially processed semiconductor wafer is received. Receiving the partially processed semiconductor wafer includes receiving a substrate including silicon and/or one or more other suitable semiconductor materials.
- (110) At operation **620**, a DRAM array is built or received in a first IC device layer. In some embodiments, building or receiving the DRAM array includes building or receiving the DRAM array in the first IC device layer being a first semiconductor wafer or die. In some embodiments, building or receiving the DRAM array includes receiving the DRAM array in the first IC device layer being the first semiconductor wafer or die as part of an IC packaging process.
- (111) In some embodiments, building or receiving the DRAM array includes building the DRAM array in the first IC device layer being a first layer of the partially processed semiconductor wafer.
- (112) Building the DRAM array in the first semiconductor wafer or die or in the first layer of the partially processed semiconductor wafer includes building a first plurality of IC devices, e.g., transistors, logic gates, memory cells, interconnect structures, and/or other suitable devices, configured to operate as discussed above with respect to DRAM array **100**A and FIGS. **1**A-**1**F.
- (113) Building the DRAM array includes performing a first plurality of manufacturing operations, e.g., one or more of a lithography, diffusion, deposition, etching, planarizing, or other operation suitable for building the first plurality of IC devices in the first IC device layer.
- (114) In some embodiments, building or receiving the DRAM array in the first IC device layer includes building or receiving DRAM array **100**A positioned in circuit C**1** of memory circuit **100**, discussed above with respect to FIGS. **1**A-**1**F.
- (115) At operation **630**, a computation circuit is built or received in a second IC device layer. In some embodiments, building or receiving the computation circuit includes building or receiving the computation circuit in the second IC device layer being a second semiconductor wafer or die. In some embodiments, building or receiving the computation circuit in the second IC device layer being the second semiconductor wafer or die as part of the IC packaging process.
- (116) In some embodiments, building or receiving the computation circuit includes building the computation circuit in the second IC device layer being a second layer of the partially processed semiconductor wafer. In some embodiments, building the computation circuit in the second layer of the partially processed semiconductor wafer includes building the second layer below the first layer of the partially processed semiconductor wafer. In some embodiments, building the computation circuit in the second layer of the partially processed semiconductor wafer includes building the second layer before building the first layer of the partially processed semiconductor wafer or die or in the second layer of the partially processed semiconductor wafer includes building a second plurality of IC

devices, e.g., transistors, logic gates, memory cells, interconnect structures, and/or other suitable

devices, configured to operate as discussed above with respect to computation circuit **100**B and FIGS. **1**A-**1**F.

- (118) Building the computation circuit includes performing a second plurality of manufacturing operations, e.g., one or more of a lithography, diffusion, deposition, etching, planarizing, or other operation suitable for building the second plurality of IC devices in the second IC device layer. (119) In some embodiments, building or receiving the computation circuit in the second IC device layer includes building or receiving computation circuit **100**B positioned in circuit C2 of memory circuit **100**, discussed above with respect to FIGS. **1A-1F**.
- (120) In some embodiments, building or receiving the computation circuit includes building or receiving computation circuit **200** discussed above with respect to FIG. **2**. In some embodiments, building or receiving the computation circuit includes building or receiving NOR gates NG coupled to sense amplifier circuit DSA and adder tree circuit **200**T, discussed above with respect to FIG. **2**. (121) In some embodiments, building or receiving the computation circuit includes building or receiving computation circuit **300** discussed above with respect to FIG. **3**. In some embodiments, building or receiving the computation circuit comprises building or receiving ADC circuit **300**ADC coupled to sense amplifier circuit ASA, discussed above with respect to FIG. **3**.
- (122) In some embodiments, building or receiving the computation circuit includes building or receiving an adder tree circuit, e.g., adder tree circuit **200**T discussed above with respect to FIGS. **2** and **3** or adder tree circuit **400** discussed above with respect to FIG. **4**.
- (123) At operation **640**, via structures are formed electrically connecting bit lines of the DRAM array to a sense amplifier circuit of the computation circuit. Forming the via structures includes forming the via structures in a boundary layer between the first and second IC device layers, e.g., boundary layer CB between circuits C1 and C2 discussed above with respect to FIGS. 1A-1F. (124) In some embodiments, forming the via structures includes forming the via structures between the first and second semiconductor wafers and/or dies as part of the IC packaging process. Forming the via structures as part of the IC packaging process includes forming one or more dielectric layers including one or more electrically insulating materials, e.g., silicon dioxide (SiO.sub.2), an epoxy, or an encapsulation material.
- (125) Forming the one or more dielectric layers includes performing one or more IC package manufacturing operations including one or more of a die separation process, a molding injection or deposition, a bonding process, an annealing process, or another process suitable for forming one or more dielectric layers as part of manufacturing an IC package.
- (126) Forming the via structures as part of the IC packaging process includes forming electrical connections in the one or more dielectric layers. Forming the electrical connections includes performing one or more manufacturing processes, e.g., a metal deposition process, a solder process, a bonding process, or another process suitable for forming electrical connections between semiconductor wafers and/or dies.
- (127) In some embodiments, forming the via structures includes forming the via structures between the first and second layers of the partially processed semiconductor wafer as part of manufacturing the partially processed semiconductor wafer.
- (128) Forming the via structures between the first and second layers includes performing a plurality of manufacturing operations including depositing and patterning one or more photoresist layers, performing one or more etching processes, and performing one or more deposition processes whereby one or more conductive materials are configured to form a continuous, low resistance structure spanning the first and second layers of the partially processed semiconductor wafer. (129) In some embodiments, forming the via structures includes forming TSV structures.
- (130) Electrically connecting the bit lines of the DRAM array to the sense amplifier circuit of the computation circuit includes forming the bit lines including the via structures. In some embodiments, electrically connecting the bit lines of the DRAM array to the sense amplifier circuit of the computation circuit includes electrically connecting bit lines B11-B1M and B21-B2M of

DRAM array **100**A to the sense amplifier circuit of computation circuit **100**B discussed above with respect to FIGS. **1**A-**1**F.

- (131) In some embodiments, electrically connecting the bit lines of the DRAM array to the sense amplifier circuit of the computation circuit includes electrically connecting bit lines B11-B1M and B21-B2M to sense amplifier circuit DSA of computation circuit 200 discussed above with respect to FIG. 2. In some embodiments, electrically connecting the bit lines of the DRAM array to the sense amplifier circuit of the computation circuit includes electrically connecting bit lines B11-B1M and B21-B2M to sense amplifier circuit ASA of computation circuit 300 discussed above with respect to FIG. 3.
- (132) At operation **650**, in some embodiments, one or more additional manufacturing operations are performed. In some embodiments, performing the one or more additional manufacturing operations includes performing one or more IC packaging operations, e.g., a bonding, encapsulation, or injection operation. In some embodiments, performing the one or more additional manufacturing operations includes performing one or more semiconductor wafer processing operations, e.g., a deposition, etch, or planarization operation.
- (133) By performing some or all of the operations of method **600**, an IC device is manufactured configured as a memory circuit including a DRAM array positioned in a first circuit and a computation circuit positioned in a second circuit, thereby obtaining the benefits discussed above with respect to memory circuit **100**.
- (134) In some embodiments, a memory circuit includes a boundary layer, a first circuit positioned on a first side of the boundary layer and including a DRAM array, wherein the DRAM array includes a plurality of DRAM cells, a second circuit positioned on a second side of the boundary layer opposite the first side and including a computation circuit, wherein the computation circuit includes a sense amplifier circuit, and a plurality of bit lines coupled to the plurality of DRAM cells and the sense amplifier circuit, wherein each bit line of the plurality of bit lines includes a via structure positioned in the boundary layer, wherein the plurality of DRAM cells of the first circuit positioned on the first side of the boundary layer is an entirety of the DRAM cells of the memory circuit coupled to the sense amplifier circuit. In some embodiments, the sense amplifier circuit includes a plurality of sense amplifiers, and each sense amplifier of the plurality of sense amplifiers includes an input terminal coupled to a bit line of the plurality of bit lines. In some embodiments, the input terminal of each sense amplifier of the plurality of sense amplifiers is coupled to more than one bit line of the plurality of bit lines. In some embodiments, each sense amplifier of the plurality of sense amplifiers includes an output terminal coupled to a corresponding NOR gate. In some embodiments, the computation circuit includes an ADC and each sense amplifier of the plurality of sense amplifiers includes an output terminal coupled to the ADC. In some embodiments, the plurality of bit lines includes the via structures positioned in the boundary layer in a single row. In some embodiments, the plurality of bit lines includes the via structures positioned in the boundary layer in multiple rows. In some embodiments, the first circuit includes a control circuit, the memory circuit includes a control line coupled between the control circuit and the sense amplifier circuit, and the control line includes a control line via structure positioned in the boundary layer.
- (135) In some embodiments, an IC device package includes a structural layer, a first semiconductor die positioned on a first side of the structural layer and including a DRAM array, wherein the DRAM array includes a plurality of DRAM cells, a second semiconductor die positioned on a second side of the structural layer opposite the first side and including a computation circuit, wherein the computation circuit includes a sense amplifier circuit, and a plurality of bit lines coupled to the plurality of DRAM cells and the sense amplifier circuit, wherein each bit line of the plurality of bit lines includes a via structure positioned in the structural layer, wherein the plurality of DRAM cells of the first semiconductor die positioned on the first side of the structural layer is an entirety of the DRAM cells of the IC device package coupled to the sense amplifier circuit. In

some embodiments, the sense amplifier circuit includes a plurality of digital sense amplifiers and each digital sense amplifier of the plurality of digital sense amplifiers includes an input terminal coupled to a bit line of the plurality of bit lines and an output terminal coupled to a corresponding NOR gate. In some embodiments, the computation circuit includes an ADC, the sense amplifier circuit includes a plurality of analog sense amplifiers, and each analog sense amplifier of the plurality of analog sense amplifiers includes an input terminal coupled to a bit line of the plurality of bit lines and an output terminal coupled to the ADC. In some embodiments, the via structures of the plurality of bit lines are arranged in a single row in the structural layer. In some embodiments, the via structures of the plurality of bit lines are arranged in multiple rows in the structural layer. In some embodiments, the first circuit includes a control circuit, the memory circuit includes a plurality of control lines coupled between the control circuit and the sense amplifier circuit, and each control line of the plurality of control lines includes a control line via structure positioned in the structural layer.

(136) In some embodiments, a method of operating a memory circuit includes generating a plurality of bit line signals from a plurality of weight data elements stored in a plurality of DRAM cells positioned on a first side of a boundary layer, propagating the plurality of bit line signals along via structures positioned in the boundary layer, receiving the plurality of bit line signals at a sense amplifier circuit of a computation circuit positioned on a second side of the boundary layer, and using the computation circuit to generate an output signal by performing one or more operations based on an input signal and sense amplifier signals generated by the sense amplifier circuit, wherein the plurality of DRAM cells positioned on the first side of the boundary layer is an entirety of the DRAM cells of the memory circuit coupled to the sense amplifier circuit. In some embodiments, performing the one or more operations based on the input signal and sense amplifier signals includes receiving the input signal and the sense amplifier signals at input terminals of a plurality of NOR gates. In some embodiments, performing the one or more operations based on the input signal and sense amplifier signals includes receiving the input signal and the sense amplifier signals at an ADC. In some embodiments, performing the one or more operations includes receiving the input signal including data elements having a number of bits equal to a number of bits of the weight data elements stored in the plurality of DRAM cells. In some embodiments, performing the one or more operations based on the input signal and sense amplifier signals includes performing a summation function, a scaling function, or a rectified linear unit function. In some embodiments, the method includes using a clock signal propagated along a control line via structure positioned in the boundary layer to synchronize generating the plurality of bit line signals and using the computation circuit to generate the output signal.

(137) The foregoing outlines features of several embodiments so that those skilled in the art may better understand the aspects of the present disclosure. Those skilled in the art should appreciate that they may readily use the present disclosure as a basis for designing or modifying other processes and structures for carrying out the same purposes and/or achieving the same advantages of the embodiments introduced herein. Those skilled in the art should also realize that such equivalent constructions do not depart from the spirit and scope of the present disclosure, and that they may make various changes, substitutions, and alterations herein without departing from the spirit and scope of the present disclosure.

Claims

1. A memory circuit comprising: a boundary layer; a first circuit positioned on a first side of the boundary layer and comprising a dynamic random-access memory (DRAM) array, wherein the DRAM array comprises a plurality of DRAM cells; a second circuit positioned on a second side of the boundary layer opposite the first side and comprising a computation circuit, wherein the computation circuit comprises a sense amplifier circuit; and a plurality of bit lines coupled to the

plurality of DRAM cells and the sense amplifier circuit, wherein each bit line of the plurality of bit lines comprises a via structure positioned in the boundary layer, wherein the plurality of DRAM cells of the first circuit positioned on the first side of the boundary layer is an entirety of the DRAM cells of the memory circuit coupled to the sense amplifier circuit.

- 2. The memory circuit of claim 1, wherein the sense amplifier circuit comprises a plurality of sense amplifiers, and each sense amplifier of the plurality of sense amplifiers comprises an input terminal coupled to a bit line of the plurality of bit lines.
- 3. The memory circuit of claim 2, wherein the input terminal of each sense amplifier of the plurality of sense amplifiers is coupled to more than one bit line of the plurality of bit lines.
- 4. The memory circuit of claim 2, wherein each sense amplifier of the plurality of sense amplifiers comprises an output terminal coupled to a corresponding NOR gate.
- 5. The memory circuit of claim 2, wherein the computation circuit further comprises an analog-to-digital-converter (ADC), and each sense amplifier of the plurality of sense amplifiers comprises an output terminal coupled to the ADC.
- 6. The memory circuit of claim 1, wherein the plurality of bit lines comprises the via structures positioned in the boundary layer in a single row.
- 7. The memory circuit of claim 1, wherein the plurality of bit lines comprises the via structures positioned in the boundary layer in multiple rows.
- 8. The memory circuit of claim 1, wherein the first circuit further comprises a control circuit, the memory circuit further comprises a control line coupled between the control circuit and the sense amplifier circuit, and the control line comprises a control line via structure positioned in the boundary layer.
- 9. An integrated circuit (IC) device package comprising: a structural layer; a first semiconductor die positioned on a first side of the structural layer and comprising a dynamic random-access memory (DRAM) array, wherein the DRAM array comprises a plurality of DRAM cells; a second semiconductor die positioned on a second side of the structural layer opposite the first side and comprising a computation circuit, wherein the computation circuit comprises a sense amplifier circuit; and a plurality of bit lines coupled to the plurality of DRAM cells and the sense amplifier circuit, wherein each bit line of the plurality of bit lines comprises a via structure positioned in the structural layer, wherein the plurality of DRAM cells of the first semiconductor die positioned on the first side of the structural layer is an entirety of the DRAM cells of the IC device package coupled to the sense amplifier circuit.
- 10. The IC device package of claim 9, wherein the sense amplifier circuit comprises a plurality of digital sense amplifiers, and each digital sense amplifier of the plurality of digital sense amplifiers comprises: an input terminal coupled to a bit line of the plurality of bit lines; and an output terminal coupled to a corresponding NOR gate.
- 11. The IC device package of claim 9, wherein the computation circuit further comprises an analog-to-digital-converter (ADC), the sense amplifier circuit comprises a plurality of analog sense amplifiers, and each analog sense amplifier of the plurality of analog sense amplifiers comprises: an input terminal coupled to a bit line of the plurality of bit lines; and an output terminal coupled to the ADC.
- 12. The IC device package of claim 9, wherein the via structures of the plurality of bit lines are arranged in a single row in the structural layer.
- 13. The IC device package of claim 9, wherein the via structures of the plurality of bit lines are arranged in multiple rows in the structural layer.
- 14. The IC device package of claim 9, wherein the first circuit further comprises a control circuit, the memory circuit further comprises a plurality of control lines coupled between the control circuit and the sense amplifier circuit, and each control line of the plurality of control lines comprises a control line via structure positioned in the structural layer.
- 15. A method of operating a memory circuit, the method comprising: generating a plurality of bit

line signals from a plurality of weight data elements stored in a plurality of dynamic random-access memory (DRAM) cells positioned on a first side of a boundary layer; propagating the plurality of bit line signals along via structures positioned in the boundary layer; receiving the plurality of bit line signals at a sense amplifier circuit of a computation circuit positioned on a second side of the boundary layer; and using the computation circuit to generate an output signal by performing one or more operations based on an input signal and sense amplifier signals generated by the sense amplifier circuit, wherein the plurality of DRAM cells positioned on the first side of the boundary layer is an entirety of the DRAM cells of the memory circuit coupled to the sense amplifier circuit. 16. The method of claim 15, wherein the performing the one or more operations based on the input signal and sense amplifier signals comprises receiving the input signal and the sense amplifier signals at input terminals of a plurality of NOR gates.

- 17. The method of claim 15, wherein the performing the one or more operations based on the input signal and sense amplifier signals comprises receiving the input signal and the sense amplifier signals at an analog-to-digital-converter (ADC).
- 18. The method of claim 15, wherein the performing the one or more operations comprises receiving the input signal comprising data elements having a number of bits equal to a number of bits of the weight data elements stored in the plurality of DRAM cells.
- 19. The method of claim 15, wherein the performing the one or more operations based on the input signal and sense amplifier signals comprises performing a summation function, a scaling function, or a rectified linear unit function.
- 20. The method of claim 15, further comprising: using a clock signal propagated along a control line via structure positioned in the boundary layer to synchronize the generating the plurality of bit line signals and the using the computation circuit to generate the output signal.